

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant(s): Kwang Choe, et al.

Examiner: Padgett, Marianne L.

Serial No.: 10/674,648

Docket No: YOR920030294US1(16817)

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Group Art Unit: 1762

Title: SOI BY OXIDATION OF
POROUS SILICON

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Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

RESPONSE UNDER 37 C.F.R. §1.111

Sir:

In response to the Office Action dated June 15, 2007 and the non-compliant amendment dated November 27, 2005, please amend the above-identified application as follows:

Amendments to the Specification begin on page 2 of this paper.

Amendments to the Claims are reflected in the listing of claims, which begin on page 3 of this paper.

Remarks begin on page 8 of this paper.

CERTIFICATE OF ELECTRONIC FILING

I hereby certify that this correspondence is being deposited with the United States Patent & Trademark Office via Electronic Filing through the United States Patent and Trademark Office e-business website, on **December 6, 2007**.

Dated: December 6, 2007



Harry Andrew Hild Jr.